

10/670,250

FORM PTO 1449 (modified) U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE LIST OF REFERENCES CITED BY APPLICANT(S) (Use several sheets if necessary)		ATTY DOCKET NO. 03500.014776		APPLICATION NO. Div. of Appln. 09/667,610	
		APPLICANT HIROKATSU MIYATA			
		FILING DATE Herewith		GROUP 1762 1771	

U.S. PATENT DOCUMENTS							
*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
WPF ↓	6120891	9/2000	Balkus et al.	428	336		
	6096469	8/2000	Anderson et al.	430	119		
	6171687	1/2001	Leung et al.	428	304.4		
	6027666	2/2000	Ozin et al.	252	301.4R		
	3962205	6/76	Ward et al.	526	352		
FOREIGN PATENT DOCUMENTS							
	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES/NO/ OR ABSTRACT	

OTHER DOCUMENT(S) (Including Author, Title, Date, Pertinent Pages, Etc.)	
WPF	"Synthesis of oriented films of mesoporous silica on mica", Hong Yang, et al. ; Nature Vol. 379, February 22, 1996, pgs. 703-705.
WPF	"Ordered mesoporous molecular sieves synthesized by a liquid-crystal template mechanism", C.R. Kresge, et al.; Nature Vol. 359, October 22, 1992, pgs. 710-712.
WPF	"Continuous formation of supported cubic and hexagonal mesoporous films by sol-gel dip-coating", Yunfeng Lu, et al. ;Nature Vol. 389, September 25, 1997, pgs. 364-68.
WPF	"Synthesis of Highly Ordered Mesoporous Materials from a Layered Polysilicate", S. Inagaki, et al.; J. Chem. Soc., Commun., 1993, pgs. 680-682.
WPF	Makoto Ogawa, "A simple sol-gel route for the preparation of silica-surfactant mesostructure materials", Chem. Commun., 1996, pp. 1149 and 1150.
WPF	Ogawa et al., "Preparation of Self-Standing Process Silica Films", Adv. Mater. 1998, Vol. 10, No. 14, 1077-1080.

EXAMINER <i>Philip F. Hottel</i>	DATE CONSIDERED <i>5/3/05</i>
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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